New n-type molecular semiconductor–doped insulator (MSDI) heterojunctions combining a triphenodioxazine (TPDO) and the lutetium bisphthalocyanine (LuPc2) for ammonia sensing

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Graphical Abstract

Highlights

- Reduced TPDO as a new active material in conductometric transducer.
- Evaporated TPDO leads to a stable n-type sensing behavior.
- Molecular material-based ammonia sensors operate at room temperature

New n-type Molecular Semiconductor - Doped Insulator (MSDI) heterojunctions combining a triphenodioxazine (TPDO) and the lutetium bisphthalocyanine (LuPc₂) for ammonia sensing

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Abstract

Molecular Semiconductor – Doped Insulator (MSDI) heterojunctions were designed using a new family of sublayers, namely triphenodioxazines (TPDO). The device obtained by combining the tetracyano triphenodioxazine bearing two triisopropylsilylethynyl moieties as a sublayer with the lutetium bisphthalocyanine (LuPc₂) as a top layer showed a nonlinear current-voltage characteristic independent of the sign of the polarization, which is the signature of MSDI heterojunctions. Thus, a TPDO was used in a chemical sensor for the first time. Despite LuPc₂ being the only material exposed to the atmosphere, the positive response of the device under ammonia revealed the key role played by the n-type TPDO sublayer. The device exhibits a response stable over time and can operate in a broad range of relative humidity.

Keywords: Triphenodioxazine; Molecular materials; Heterojunctions; Conductometric transducer; Ammonia

1. Introduction

The wide attention that has been given to organic electronic devices over the past decades was due to their expected straightforward and low-cost processing through printing

technologies as well as the possibility of designing flexible systems. In addition, new logic circuits and organic solar cells involve a suitable combination of p-type and n-type organic semiconductors. For example, a blend of poly-3-hexylthiophene and PCBM (a C60 derivative) used as p-type and n-type materials respectively is well known for its photovoltaic properties [1]. However, the number of n-type organic materials is so far rather limited compared to hole (p-type) transporting materials. Thus, many efforts are currently devoted to the development of stable n-type organic semiconductors and to their integrations into n-type organic field-effect transistors and logic circuits [2-5].

A few years ago, Bouvet *et al.* introduced a new type of heterojunction [6], which is built from a rather poor conducting molecular material as sublayer covered by a highly conductive molecular material, the lutetium bisphthalocyanine (LuPc₂, Scheme 1). Since the resistive sublayer is much thinner than the interelectrode distance, under polarization, charges have to move across the interface between the two molecular materials in order to take the most conductive pathway when applying a bias voltage, as shown in Fig. 1. This device has been named MSDI, which stands for Molecular Semiconductor – Doped Insulator heterojunction [7]. It is worth underlying that a MSDI is neither a p-n junction nor a transistor, and has its own current-voltage characteristics. Owing to its particularly low energy gap, ca. 0.5 eV [8,9], resulting from its radical nature, the lutetium bisphthalocyanine exhibits a high density of positive and negative charge carriers, and, therefore, shows ambipolar conducting properties. Thus, LuPc₂ is the first molecular semiconductor to have led to a n-channel in an OFET [10].

Scheme 1. Top view of LuPc₂ along its C₄ axis (left) and schematic view of the tetracyano-TIPS-TPDO (right).

This architecture involving LuPc₂ exhibits very specific response when exposed to gases. Using pure n-type sublayers, such as metalloperfluorophthalocyanines, M(F₁₆Pc), the response to ammonia is positive whereas the electrical current decreases for a LuPc₂ resistor. On the other hand, with a pure p-type sublayer, e.g. pentacene, oligothiophene or a nonsubstituted phthalocyanine [7,11], ammonia induces a decrease in the current through the MSDI. An important point about MSDIs is that the only material that can interact with the outer atmosphere is the top layer. Nevertheless, we showed that the transport properties are dominated not only by the energy barrier at the interface between the sublayer and the LuPc₂ top layer, but also by the Schottky contact between the sublayer and the electrodes [12]. These energy barriers are higher with M(F₁₆Pc) than with p-type sublayers.

Figure 1. Schematic view of a Molecular Semiconductor – Doped Insulator (MSDI) heterojunction (left) compared to a resistor (right); the arrows indicate the main channel for charge carriers.

Beside perfluorinated phthalocyanines [13], only few molecular materials exhibit an n-type behavior in air. The most popular are naphthalene diimide and perylene diimide derivatives [4,14-16], C₆₀ [17,18] and fluorinated oligothiophenes [5]. On the other hand, triphenodioxazine (TPDO) is a well-known π -conjugated core found in different dyes or pigments [19] that has recently found new promising development in the field of organic solar cells [20], dye-sensitized solar cells [21], luminescent devices [22] and organic field-effect transistors [23,24]. For instance, triphenodioxazines (TPDOs) bearing triisopropylsilylethynyl (TIPS) groups were introduced as new soluble n-type materials [21,24] (scheme 1). More interestingly, tetracyano-TIPS-TPDO proved to be an efficient material for liquid-processed air-stable n-type OFET [25,26].

In the present paper, we report on the behavior of MSDI heterojunctions combining the tetracyano-TIPS-TPDO and the lutetium bisphthalocyanine LuPc₂ (Scheme 1). Their current-

voltage characteristics are compared to those of resistors prepared from one of these two molecular materials. Their response to ammonia is studied in the 10-100 ppm range, in synthetic air.

2. Experimental

2.1. Chemicals

Previously reported procedures were followed to prepare LuPc₂ [27,28] and tetracyano-TIPS-TPDO [25]. Chloroform and chlorobenzene are used as solvent for spin coating. Polystyrene (M = 280 000) and other chemicals are purchased from (Sigma-Aldrich) and used as received.

2.2. Characterizations

The UV-visible absorption spectra were registered using a Varian UV-vis spectrophotometer Cary 50, between 350 nm and 850 nm. Field Desorption (FD) mass spectra were performed by the CESAMO (Bordeaux, France). The measurements were carried out on a TOF mass spectrometer AccuTOF GCv by JEOL using an FD emitter with an emitter voltage of 10 kV. One to two microliters solution of the compound was deposited on a 13 μ m emitter wire. Thermogravimetric analyses were carried out on a Netzsch STA simultaneous analyzer using alumina crucibles.

2.3. Electrical and chemosensing measurements

Electrical measurements were carried out with Indium Tin Oxide (ITO) interdigitated electrodes (IDE) deposited onto a 1 x 1 cm² glass substrate and separated by 75 μ m. Their thickness was 50 nm and their total length 15 cm. Thin films of molecular materials were prepared either by sublimation under secondary vacuum (ca. 10⁻⁶ mbar) in a UNIVEX 250 thermal evaporator (Oerlikon, Germany), at a rate of ca. 0.3 $\text{\AA s}^{-1}$, by heating in a temperature range of 320-350 °C for TPDO and at a rate of 1 $\text{\AA s}^{-1}$, 450-500 °C for LuPc₂, or by the spin coating technique. Thus, films of pure TPDO and films of TPDO mixed with 13% (w/w) of polystyrene were prepared from chloroform/chlorobenzene 9/1 solutions. The temperature of the solution was raised to 50°C before spin coating. The workbench used for the study of ammonia sensing was described previously [29]. Ammonia gas (NH₃), 1000 ppm in synthetic air, and synthetic air were used from standard cylinders, purchased from Air Liquide, France. The total

flow was in the 0.5-0.55 NL min⁻¹ range, depending on ammonia concentration, and the volume of the test chamber was 8 cm³. Gas sensing experiments were carried out in a dynamic way, with 4 min-long rest periods alternating with 1 min-long exposure periods. In the present study, all the exposures to NH₃ were carried out in dry air and at the lab temperature (18–22 °C, unless otherwise specified).

3. Results and Discussion

After deposition of TPDO by spin coating, LuPc₂ (50 nm) was deposited by evaporation under secondary vacuum. The UV-visible spectrum of the resulting bilayer film exhibits the main absorption bands of TPDO, between 500 and 650 nm [24,25], with a peak at 638 nm, and of LuPc₂, with its Q band at 668 nm and the weak band at 467 nm attributed to a transition between a filled orbital and the SOMO (Fig. 2) [30,31].

Figure 2. UV-vis absorption spectrum of a spin coated TPDO/LuPc₂ (black line) bilayer deposited on a glass substrate compared to the spectra of spin coated TPDO (red, dotted line) and evaporated LuPc₂ (green, dashed line) films.

The I-V characteristics, registered from -10 to +10 V, are symmetrical and slightly nonlinear, with a current of 7x10⁻⁵ A at 10 V (Fig. 3 left). Under a constant polarization of 1 V, the device exhibits a current increase under NH₃ (Fig. 3 right), as expected for a n-type MSDI. This clearly confirms the n-nature of the majority charge carriers in the TPDO sublayer. Indeed, MSDIs built with a p-type sublayer lead to a negative response to donating species like NH₃ [7]. However, the response is rather poor. With

exposure/recovery cycles of 1 min/4 min, the relative response to 90 ppm NH_3 after a 1 min-long exposure period, defined as $(I-I_0)/I_0$, where I and I_0 are the current values at the end and at the beginning of exposure periods, respectively, is only 0.2 %. More important is the evolution of the transport properties of the device. After a series of expositions to NH_3 /rest under synthetic air cycles, the I-V characteristics become linear and NH_3 induces a current decrease, indicating a modification of the electronic transport through the device, the origin of which remains unknown. This behavior was observed for samples prepared with pure TPDO and also for these from TPDO solutions containing 13 % (w/w) of polystyrene.

Figure 3. Typical I-V characteristic of a spin coated TPDO/LuPc₂ MSDI (left) and its response to 90 ppm of NH_3 (exposure duration: 15 min) in dry synthetic air when polarized at 1 V (right).

This is the reason why devices were prepared by vacuum evaporation of both components, TPDO and LuPc₂, with thicknesses of 50 nm each. They showed a significantly different behavior. In particular, their electrical characteristics and their chemosensing responses remain stable over time. The I-V characteristics are symmetrical and nonlinear, with a current of $1.35 \times 10^2 \mu\text{A}$ at 10 V (Fig. 4). When exposed to NH_3 , the current increases sharply during the first minute, up to a plateau, and a full reversibility is observed under synthetic air, as depicted from 15 min/1 h exposure/rest cycles (Fig. 5). Again, this positive response to NH_3 is the signature of a n-type MSDI.

Figure 4. Typical I-V characteristic of a vacuum evaporated TPDO/LuPc₂ MSDI.

Figure 5. Current variation as a function of time of a vacuum deposited TPDO/LuPc₂ MSDI, polarized at 1 V, exposed to 90 ppm NH₃ for 15 min-long periods separated by 1 h-long rest periods in dry synthetic air.

When submitted to repeated exposure/recovery cycles with exposure periods of 1 min separated by a 4 min-long recovery period under a synthetic air flow, the device shows a good reversibility, with only a slight drift. The response depends on the NH₃ concentration, as depicted from Fig. 6, in the 30-90 ppm range. The relative response is about 11% at 30 ppm,

which is as much as that of the most sensitive n-MSDI reported so far, namely the MSDIs prepared with perfluorophthalocyanine complexes as a sublayer.

Figure 6. Response of a vacuum deposited TPDO/LuPc₂ MSDI to NH₃ in the range 30-90 ppm), in dry atmosphere, during exposure/recovery cycles (1 min/4 min), polarized at 1 V.

In comparison, a resistor made of a vacuum deposited TPDO film in the same conditions exhibits a much lower current, about 10^{-9} A under 10 V. This increases under ammonia, by 6% after one minute at 50 ppm. However, the response changes only slightly between 25 ppm and 90 ppm (Fig. 7). Again, this curve shows the n-type character of the material. The important drift of the current with and without ammonia limits highly the interest of such a resistor. This drift was also observed when the resistor was exposed to 90 ppm of NH₃ during 15 min/60 min exposure/recovery cycles (Fig. S1). The current drift is so high, with and without ammonia, that no plateau is visible. In turn, it highlights the advantages of the MSDI heterojunctions compared to resistors.

Figure 7. Current variation as a function of time of a vacuum deposited TPDO resistor, polarized at 10 V, exposed to ammonia in dry synthetic air at different concentrations for 1 min-long periods spaced by a 4 min-long rest period under dry synthetic air. The ammonia concentration at each cycle is indicated on the right scale.

Figure 8. Absorption spectra of a vacuum evaporated TPDO/LuPc₂ MSDI (50 nm/50 nm) (top, black line) and of a vacuum evaporated TPDO resistor (50 nm, red dotted line)

The UV-visible absorption spectra of vacuum evaporated TPDO films with and without LuPc₂ as a top layer (Fig. 8) are different from those expected for TPDO and obtained by spin coating (Fig. 2) [24,25]. In particular, additional bands appear in the vacuum evaporated TPDO films, which are centered at 459, 485 and 581 nm, while the λ_{max} of spin coated TPDO films lies at 638 nm. In the corresponding MSDIs, additionally to the Q band of LuPc₂ (668 nm), another feature is the absorption at 460 nm, related to the radical nature of LuPc₂ [30,31], that becomes equal to this at 479 nm, owing to the absorption of both materials at this wavelength. The broad band centered at 596 nm results also from both materials, whereas the band at 638 nm (Fig. 2) corresponding to TPDO disappeared. These differences with the expected spectra are not due to a degradation of the TPDO molecule since it starts above 350 °C as depicted from thermogravimetric analyses. In addition, the mass spectrum of the evaporated derivative shows a main peak at an exact mass of 748.3365, which can be assigned to the diprotonated molecule, H₂TPDO (Fig. 9). The mass difference with the chemical formula, C₄₄H₄₈N₆O₂Si₂, is of 1.59 ppm, which is a very small value sign of an unambiguous assignment. For the native TPDO, the exact mass is 746.3193 (M), and the first fragmentation corresponds to the loss of one of the propyl groups (M-43). This new formula (H₂TPDO) corresponds to a reduction of the starting TPDO by two electrons and two protons, analogous to the reduction of quinones into dihydroquinones [32]. This reduction can occur at the quinonediimine level, by its transformation into its diamino analogue (Fig 9) [33]. Another characteristic of the reduced derivative is its thin vibration band at 3372 cm⁻¹, attributed undoubtedly to a stretching vibration of a N-H bond, which is absent in TPDO. The study of the reduction of TPDO in solution will be reported elsewhere [34]. While the native quinonediimine form of TPDO is stable in air, the reduced form, H₂TPDO, is produced during heating under secondary vacuum ($P = 10^{-6}$ mbar). The only way to explain the existence of this reduced form in the solid state is to take into account the intermolecular interactions, mainly π - π interactions and H-bonds, since the reduced form owns two additional H atoms, bear by nitrogen atoms, capable to form H-bonds with neighboring molecules.

Figure 9. Mass spectra of the triphenodioxazine derivative (bottom) and its reduced form (top) obtained in positive mode. Chemical structures (only the two additional H atoms are shown in the reduced form), radical lost fragment, exact mass and differences with theoretical mass are inserted.

Resistors based on substituted bisphthalocyanine complexes with a good sensitivity to NH_3 have been reported [35], with a positive or negative response, depending on the peripheral substitution of the macrocycles. However, clearly, as for the resistor made from TPDO derivatives in the present study, there is an important drift of the current over time. In an example [36] a response of ca. 2 % at 10 ppm NH_3 was reported but the current-time curve was noisy. We want to point out that the current response of MSDIs does not suffer this drawback. We previously underlined the advantage of n-type MSDIs for chemosensing (see for examples [6] and [11]). In particular, the high sensitivity of the radical $LuPc_2$ top layer is kept, but with a higher stability of the response over time compared to resistors made from one of the components. Moreover, with a n-type sublayer, the response to NH_3 is positive (current increase), which is always an advantage compared to a negative response. n-Type

semiconductors offer this advantage, but due to their poor long term stability in air, their use in resistors is *de facto* very limited. Their use in MSDI heterojunctions offers the opportunity to keep the advantage of n-type materials to detect electrodonating gases without their instability in air. A key difference between conventional resistors and n-MSDIs is that the responses to ammonia and humidity are inverted in n-MSDIs whereas these species act both as donating species in resistors. The effect of water was interpreted as an effect of trapping of positive charge carriers by water molecules leading to a decrease of the energy barrier in MSDIs, then an increase of the current going through the device. The effect of ammonia is the neutralization of positive charge carriers by ammonia leading to an increase in minority (negative) charge carriers, which govern the transport properties of n-type MSDIs [12].

The response of the vacuum evaporated TPDO/LuPc₂ MSDI towards NH₃ was study under humidity, in the range 10-70 % (Fig. 10). The humidity decrease induces a slight drift of the current, by 4.5 % from 70 % rh to 10 % rh. This variation is lower than the response to 30 ppm NH₃. The response to NH₃ increases with the rh value, from 9.1 % to 14.8 % at 30 ppm NH₃ when the rh increases from 10 % to 70 %.

Figure 10. Response of a vacuum evaporated TPDO/LuPc₂ MSDI (solid line) to NH₃ (90, 60 and 30 ppm, dotted line), with relative humidity in the range 10-70 % (dashed line), during exposure/recovery cycles (1 min/4 min), polarized at 2 V. The temperature was 23.5 °C.

Up to now the reported n-type MSDI heterojunctions were limited to perylene derivatives and perfluorophthalocyanines. We already demonstrated a long-term stability of the chemosensing behavior of n-MSDIs with a perfluorophthalocyanine complex as a sublayer, namely several years [12]. On the contrary, perylene derivatives that exhibit rather nice responses to NH_3 lead to sensors with a rather poor stability over time [29].

The present MSDIs have been submitted to 30 ppm NH_3 during twenty exposure/recovery cycles (1 min/4 min) at 50 % rh (Fig. 11). A small drift appears for the current with and without NH_3 and the relative response remains constant over all the experiment, at $14.9\% \pm 0.1$.

Figure 11. Response of a vacuum evaporated TPDO/LuPc₂ MSDI (solid line) to 30 ppm NH_3 (dotted line) at a relative humidity of 50 %, during twenty exposure/recovery cycles (1 min/4 min), polarized at 2 V. The temperature was 23.5 °C.

So, with this present work we showed the interest of TPDO derivatives as a component in such conductometric sensors. It opens the way for new applications for this family of n-type materials already used in organic electronics, but in OFETs and in photovoltaic cells.

4. Conclusion

Sensing ammonia with an MSDI involving LuPc₂ and tetracyano-TPDO confirms the n-type character of the conductivity of TPDO. The reduced form of the tetracyano-TPDO obtained during its vacuum evaporation revealed to be also a n-type material, with a better stability of its electrical and chemosensing properties when associated to LuPc₂ in MSDI devices. The positive response to NH₃ is high enough for its detection in the range 10-100 ppm, which is interesting for many applications. Thus, in chemical industry, the threshold of 50 ppm is generally considered, and the European air quality labor legislation sets the daily exposure limit to 20 ppm for NH₃ [37]. It also confirms, if needed, that the MSDI device is a versatile conductometric transducer, capable of accommodating many molecular materials, and of operating at room temperature. TPDO derivatives favorably compete previous materials leading to n-type MSDIs, namely perfluorophthalocyanines and perylene derivatives.

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